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Part Two of Two Parts

SPIE is an international technical society dedicated to advancing engineering and scientific applications of optical, photonic, imaging, electronic, and optoelectronic technologies.

Part Two

- 431 **Diffractive optical elements for shaping Gaussian Schell-model beams** [5636-66]
H. Kim, T. Kim, K. Choi, S. Han, I. Lee, B. Lee, Seoul National Univ. (South Korea)
- 440 **A tunable cyclic encoder using photopolymer-based holographic grating for optical CDMA application** [5636-67]
S. Chung, T. Kim, S. Han, B. Lee, Seoul National Univ. (South Korea)
- 447 **Virtual input device with diffractive optical element** [5636-68]
C. C. Wu, C. S. Chu, Industrial Technology Research Institute (Taiwan, China)
- 455 **The analysis of a confocal fluorescent microscope with laser scanning microarray system** [5636-69]
W. Yuan, J. Ma, D. Fu, L. Hou, J. Chen, Univ. of Shanghai for Science and Technology (China)
- 459 **All-digital holography and application in digital image hiding** [5636-70]
Y. Zhao, J. Zhong, Jinan Univ. (China)
- 467 **A simple method for holographic recording of images in different polarization states using a fiber bundle with rotary movement** [5636-71]
Y. Takayama, National Institute of Information and Communications Technology (Japan); Y. Okazaki, Japan Women's Univ. (Japan); T. Aruga, National Institute of Information and Communications Technology (Japan); K. Kodate, Japan Women's Univ. (Japan)

- 475 **Optimization of holographic polymer-dispersed liquid crystals using siloxane-containing materials** [5636-73]
Y. H. Cho, Japan Advanced Institute of Science and Technology (Japan); N. Kim, Chungbuk National Univ. (South Korea); Y. Kawakami, Japan Advanced Institute of Science and Technology (Japan)
- 483 **The fabrication model of Fresnel diffractive lens with transverse-adding technique** [5636-74]
M. Chen, Nanjing Univ. of Aeronautics and Astronautics (China) and Nanchang Institute of Aeronautical Technology (China); S. Yu, Nanjing Univ. of Aeronautics and Astronautics (China); Y. Gao, D. Yu, X. Qi, Nanchang Institute of Aeronautical Technology (China); T. Chen, Nanchang Institute of Aeronautical Technology (China) and National Univ. of Defense Technology (China)
- 491 **The influence of wavefront of the writing beams on angle Bragg selectivity in volume holographic storage** [5636-75]
W. Lu, Nankai Univ. (China); Y. Li, J. Xu, Q. Sun, Nankai Univ. (China) and Key Lab. of Advanced Technique and Fabrication for Weak-Light Nonlinear Photonics Materials (China)
- 495 **Fabrication of varied-line-space grating by elastic optics** [5636-76]
Y. Xie, S. He, S. Fu, Univ. of Science and Technology of China (China)
- 499 **A fluctuation-insensitive diffractive optical homogenizer for excimer beam shaping** [5636-78]
G. Zheng, C. Du, Institute of Optics and Electronics, CAS (China)
- 505 **Study on photorefractive property of Mg:Fe:LiNbO₃ crystal** [5636-79]
Z. Xu, S. Xu, Y. Xu, R. Wang, Harbin Institute of Technology (China)
- 512 **Noise-free readout in holographic storage by concave mirror** [5636-80]
W. Lu, Nankai Univ. (China); Y. Li, J. Xu, Q. Sun, Nankai Univ. (China) and Key Lab. of Advanced Technique and Fabrication for Weak-Light Nonlinear Photonics Materials (China)
- 515 **Vector analyzing for diffraction of gratings: experimental studies** [5636-81]
P. Dong, H. Gao, B. Wang, L. Xie, L. Rong, J. Zhou, D. Liu, Applied Optics Lab., Beijing Normal Univ. (China)
- 519 **Analysis and design of grating lens by using rigorous electromagnetic theory** [5636-83]
X. Tang, F. Gao, F. Gao, Y. Zhang, J. Du, Y. Guo, Sichuan Univ. (China); C. Du, Institute of Optics and Electronics, CAS (China)
- 528 **Characterization of a real-time high-sensitivity photopolymer for holographic display and holographic interferometry** [5636-84]
X. Guo, J. Zhu, C. Xia, J. Li, L. Chen, Sichuan Univ. (China)
- 538 **Design and fabrication of two-dimensional nonseparable Dammann gratings** [5636-85]
C. Wang, C. Du, L. Pan, Q. Liu, Institute of Optics and Electronics, CAS (China)
- 546 **Electromagnetic analysis of diffractive lens with C method and local linear grating model** [5636-86]
K. Xiao, Y. Liu, S. Fu, Univ. of Science and Technology of China (China)

- 551 **Design of variable-line-space plane gratings with holographic recording** [5636-87]
J. Lou, Y. Liu, S. Fu, X. Xu, S. He, Univ. of Science and Technology of China (China)
- 560 **Formation and characterization of transmission holographic gratings obtained using a novel siloxane-containing liquid crystal** [5636-88]
M. He, Y. H. Cho, Japan Advanced Institute of Science and Technology (Japan); N. Kim, Chungbuk National Univ. (South Korea); Y. Kawakami, Japan Advanced Institute of Science and Technology (Japan)
- 568 **Near-field diffraction analysis of color-separating gratings under high-power laser condition** [5636-89]
F. Gao, X. Tang, S. Wen, J. Du, Y. Guo, Sichuan Univ. (China); J. Yao, Durham Univ. (United Kingdom)
- 576 **Reactive ion beam etching of HfO_2 film using Ar/CHF₃ gas chemistries** [5636-90]
X. Wang, Univ. of Science and Technology of China (China) and Hefei Univ. of Technology (China); X. Xu, Y. Liu, Y. Hong, S. Fu, Univ. of Science and Technology of China (China)
- 581 **Synthetic aperture holography by movement of object** [5636-92]
Y. Zhang, X. Lü, Y. Luo, L. Zhong, C. She, Kunming Univ. of Science and Technology (China)
- 589 **Long-term retrieving experiment on rewritable holographic memory with dynamic refreshment by mutual-pumped phase conjugator** [5636-93]
H. Funakoshi, A. Okamoto, Hokkaido Univ. (Japan); K. Sato, Hokkai-Gakuen Univ. (Japan)
- 597 **Influence of fabrication parameters on groove profile of blazed gratings made with two-step holographic technique** [5636-94]
S. Li, S. Liu, X. Zhang, Y. Liu, X. Ren, Xiamen Univ. (China)
- 606 **Research for the image color of the ordinary transmission holograms displaying with a white light source and grating** [5636-95]
X. R. He, M. X. Chen, W. P. Zhang, Guangxi Univ. (China); X. M. Shen, Tongji Univ. (China)
- 611 **Study on the fabrication of combined BSG-CSG element** [5636-96]
Y. Zhang, F. Gao, S. Wen, Q. Liu, Y. Guo, Sichuan Univ. (China); J. Zhang, Institute of Electro-Optical Technology (China)
- 621 **Design and fabrication of a variable optical attenuator based on polymer-dispersed liquid crystal** [5636-97]
J. She, S. Xu, T. Tao, Q. Wang, Zhejiang Univ. (China)
- 630 **Computer-generated hologram of asymmetry fractional Fourier transform** [5636-98]
Z. Sheng, H. Wang, J. He, Y. Zhou, J. Wang, C. Mao, Xi'an Hongqiang Insitute of High Technology (China)
- 635 **Water-resisting compound red-sensitive photopolymer: mechanism and optimization of components** [5636-99]
X. Hu, H. Zhang, G. Zhang, Y. Sheng, Y. Wang, R. Zhao, Capital Normal Univ. (China)
- 646 **Speckle average technique for DSPI static deformation measurement** [5636-100]
S. Jia, J. Zhao, Xi'an Jiaotong Univ. (China)

- 651 **The growth and photorefractive effect of codoped Ce:Cu:BGO crystals** [5636-101]
W. Zheng, F. Wang, Y. Xu, Harbin Univ. of Science and Technology (China)
- 656 **Compound sensitizing for improving exposure sensitivities of photopolymer system**
[5636-103]
Y. Sheng, H. Zhang, X. Hu, R. Zhao, Y. Wang, Capital Normal Univ. (China)
- 661 **Deep-etched fused silica grating as a (de)multiplexer for DWDM application at the 1.55- μ m wavelength** [5636-104]
Y. Zhang, C. Zhou, H. Ru, S. Wang, Shanghai Institute of Optics and Fine Mechanics, CAS (China)
- 666 **Microlens array for stacked laser diode beam collimation** [5636-105]
Q. Deng, C. Du, C. Wang, C. Zhou, X. Dong, Y. Liu, T. Zhou, Institute of Optics and Electronics, CAS (China)
- 671 **Showing display holograms in holography teaching** [5636-106]
D. Hsu, Beijing Univ. of Posts and Telecommunications (China); Y. Mao, Chongqing Univ. of Posts and Telecommunications (China); Q. Zhang, L. Liu, Beijing Univ. of Posts and Telecommunications (China)
- 677 **Fabrication of holographic photonic crystal template with back incident interference beams** [5636-107]
Y. Liu, S. Liu, X. Zhang, S. Li, X. Ren, Xiamen Univ. (China)
- 685 **All-optical interconnection with mutually pumped four-wave mixing and optimization for high-connection efficiency** [5636-108]
S. Honma, S. Muto, Yamanashi Univ. (Japan); A. Okamoto, Hokkaido Univ. (Japan)
- 695 **Feasibility of holographic off-plane waveguide coupler for coupling optical beams to photopolymer waveguide** [5636-109]
T. Kim, H. Kim, S. Han, B. Lee, Seoul National Univ. (South Korea)
- 703 **Digital hologram's image-forming system** [5636-110]
Y. Wang, H. Zhang, X. Hu, Capital Normal Univ. (China)
- 712 **Continuous micro-optics fabrication using halftone masks and proximity printing** [5636-111]
C. Qiu, C. Wang, C. Du, X. Dong, Institute of Optics and Electronics, CAS (China)
- 717 **A theoretical and experimental study on the spectral secondary peak characteristics of holographic reflection gratings** [5636-112]
X. He, Beijing Normal Univ. (China) and Nanchang Institute of Aeronautical Technology (China); D. Liu, J. Zhou, Beijing Normal Univ. (China); L. Fang, X. Wang, Nanchang Institute of Aeronautical Technology (China)
- 728 **Laser scattering of a bubble in water** [5636-113]
X. Deng, H. Ye, D. Tan, Huazhong Univ. of Science and Technology (China); X. Zhang, Navy Engineering Univ. (China); K. Yang, Huazhong Univ. of Science and Technology (China); Q. Liu, X. Lei, Navy Engineering Univ. (China); L. Yu, M. Xia, W. Li, Huazhong Univ. of Science and Technology (China)

- 734 **Study on mechanism and experiments of optical fixing of holograms on doubly doped Fe:Mn:LiNbO₃ crystal** [5636-114]
 R. Guo, H. Shi, X. Sun, Harbin Institute of Technology (China)
- 744 **Detailed research of the performance of bidirectionally pumped Raman fiber amplifier** [5636-116]
 X. Xin, Beijing Univ. of Posts and Telecommunications (China) and Institute of Telecommunications (Portugal); C. Yu, Beijing Univ. of Posts and Telecommunications (China); P. S. B. Andre, A. L. J. Teixeira, Institute of Telecommunications (Portugal) and Univ. of Aveiro (Portugal); Q. Zhang, A. Li, Beijing Univ. of Posts and Telecommunications (China); P. M. Monteiro, Siemens SA (Portugal)
- 749 **Holographic polymer Bragg gratings for dense wavelength division multiplexing at 1550 nm** [5636-117]
 W. Wang, M. Xu, Y. Xia, M. Chen, J. Liang, S. Ma, Changchun Institute of Optics, Fine Mechanics and Physics, CAS (China)
- 757 **Numerical reconstruction of three-dimensional image using modified triangular interferometer** [5636-118]
 S.-G. Kim, Hoseo Univ. (South Korea); E.-S. Kim, Kwangwoon Univ. (South Korea)
- 765 **Optimization design of tellurium dioxide acousto-optic tunable filters for WDM systems** [5636-119]
 W. Liu, Beijing Institute of Technology (China) and Capital Normal Univ. (China); L. Ban, M. Lv, J. Cui, F. Cui, Y. Sun, Beijing Institute of Technology (China)
- 773 **Two-channel kinoform by micro-optical technique** [5636-121]
 R. Mu, X. Ji, L. Han, C. Zhong, Nantong Univ. (China)
- 779 **Observation of diffractive effect with a supercontinuum laser pulse** [5636-122]
 T. Harimoto, Univ. of Yamanashi (Japan); Y. Takeuchi, Osaka Univ. (Japan); M. Fujita, Institute for Laser Technology (Japan)
- 786 **The performance of a novel multirate OCDMA system** [5636-123]
 Q. Zhang, Beijing Univ. of Posts and Telecommunications (China); Y. Mao, Chongqing Univ. of Posts and Telecommunications (China); D. Hsu, C. Yu, Z. Chen, S. Wang, J. Wang, Beijing Univ. of Posts and Telecommunications (China)
- 794 **Spectral efficiency of incoherent OCDMA systems** [5636-124]
 Z. Chen, C. Yu, Q. Zhang, Z. Yu, D. Xu, Beijing Univ. of Posts and Telecommunications (China)
- 802 **Holographic recording of superimposed gratings by angle multiplexing in photopolymers with light-induced changing of optical absorption** [5636-125]
 S. N. Sharangovich, V. A. Kuznechov, Tomsk State Univ. of Control Systems and Radioelectronics (Russia); V. V. Shelkovnikov, Novosibirsk Institute of Organic Chemistry (Russia); E. F. Pen, Institute of Automation and Electrometry (Russia)
- 812 **Long focal depth zone plate for optical coherence tomography** [5636-126]
 F. Gao, J. Liu, B. Luo, X. Yao, B. Liu, Y. Guo, Sichuan Univ. (China); C. Wang, State Key Lab. of Optical Technology on Microfabrication, CAS (China)

- 820 **Fabrication of apodized grating in photopolymer using SLM** [5636-127]
D.-D. Do, J. Kim, N. Kim, Chungbuk National Univ. (South Korea); S.-K. Gil, Suwon Univ. (South Korea); K.-Y. Lee, Sunchon National Univ. (South Korea); M. C. Paek, Electronics and Telecommunications Research Institute (South Korea)
- 828 **Experimental research on measuring image energy in the spectrum imaging system** [5636-128]
M. X. Chen, X. R. He, W. P. Zhang, X. F. Li, Guangxi Univ. (China)
- 833 **Study and design on a facilitated system of fiber grating sensor** [5636-129]
Z. Zhang, K. Wang, C. Yu, X. Wang, B. Yan, Beijing Univ. of Posts and Telecommunications (China)
- 842 **Properties of volume holograms recording in photopolymer films with various pulse exposures repetition frequencies** [5636-131]
Q. He, H. Wei, S. He, G. Jin, M. Wu, Tsinghua Univ. (China)
- 849 **A new method for eliminating zero-order and conjugate image in digital holography** [5636-132]
W. Wang, W. Yue, L. Ai, Capital Normal Univ. (China)
- 856 **A study on multispectral projection moiré measurement** [5636-133]
N. Zhang, K. Yang, Huazhong Univ. of Science and Technology (China)
- 867 *Author Index*